

Conceptual design of the Hybrid positron source

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Positron source group

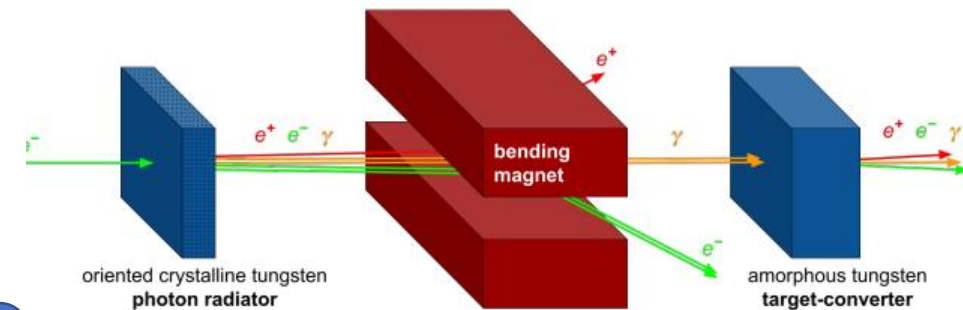
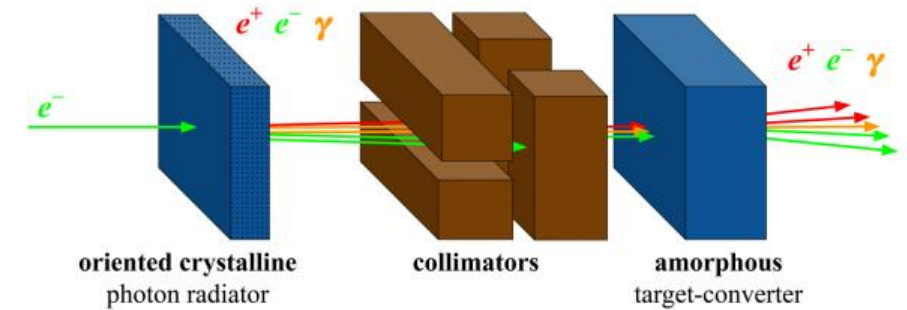
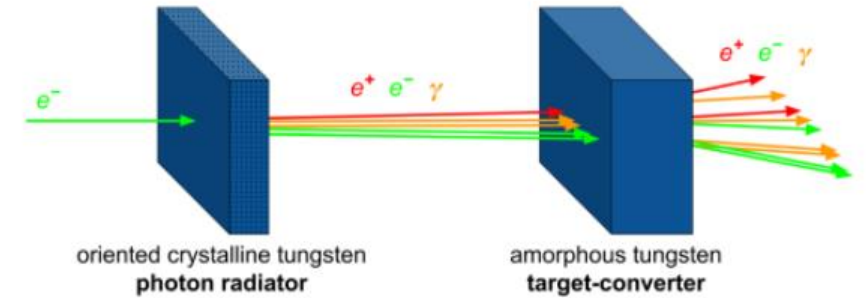
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Hybrid scheme for the positron production (channeling radiation)

- Innovative scheme for positron production in collaboration with INFN- Ferrara.
- Production scheme is composed of two elements :
 - 1) Oriented crystal (Channeling radiation)
 - 2) Amorphous target (Pair production)
- Advantage : Lower energy deposition in the target.
- 8 different configurations (0.6m, 1m, 2m)
 - **W-Crystal $\langle 111 \rangle$ thickness = 2mm**
 - **Amorphous target thickness = 11.6mm (optimized)**

* “ Radiation in oriented crystals: innovative application to future positron sources”



Simulation environment

Channeling Radiation
Ferrara-code

Positron production
G4

AMD (HTS)
RFT- Volume

RF Structures
RFT- Lattice

Positron Linac
Analytical formula

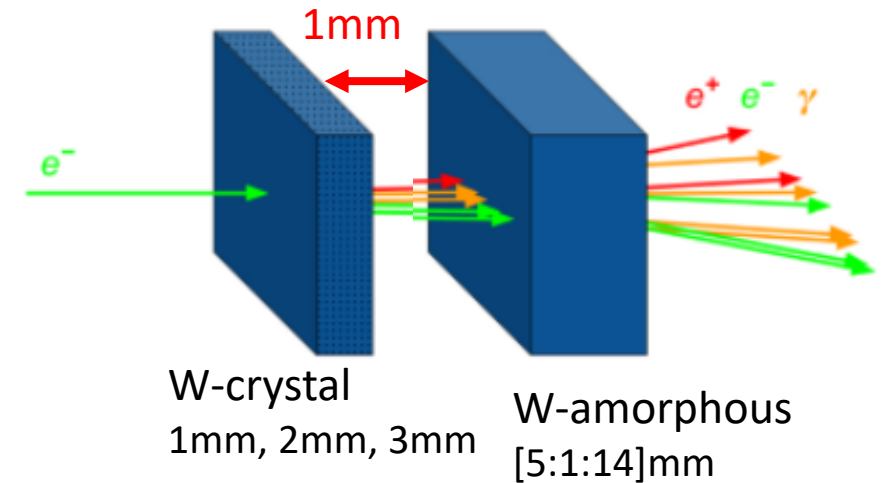
Summary table

13.5nC at DR

Case	Target				AMD		Capture Linac			Positron Linac		e- beam	Target	
	Rate	σx [mm]	Edep [GeV/e-]	PEDD [$\frac{MeV}{mm^3}/e^-$]	Yield (AMD) R = 30mm	Coll. Eff. [%]	Yield	Mean Energy [MeV]	Energy Spread [%]	Bunch Length [mm]	Accept Yield	Drive beam charge [nC]	PEDD [J/g]	Deposited Power [kWs]
0 – Conv.	14.4	0.85	1.46	38.3	13.1	91.3	8.6	196.0	23.2	3.1	7.0	1.93	7.67	1.13
1-0.6m_drift	15.1	2.02	1.34	12.8	11.8	78.5	6.3	190.6	20.8	3.0	5.0	~2.7	3.61	1.45
2- 0.6m_coll	13.6	1.71	1.13	12.5	11.9	87	6.4	190.4	20.8	3.1	5.1		3.43	1.22
3 - 1m_drift	15.1	3.03	1.32	8.4	10.4	69.2	5.1	189.7	22	3.0	4.0	~ 3.4	2.95	1.80
4- 1m_coll	12.6	2.54	1.13	8.2	10.4	76.7	5.1	190	22	3.0	4.0		2.89	1.54
5- 1m_magn	15	3.01	1.32	8.4	10.4	69.2	5	189.9	22.6	3.0	3.98		2.97	1.80
6- 2m_drift	15	5.54	1.27	4.1	7.7	51.3	3.3	188.6	22.5	3.1	2.59	~5.2	2.2	2.64
7- 2m_coll	13.7	4.68	1.11	3.8	7.7	56.4	3.3	189.1	26.8	3.1	2.6		2.06	2.31
8- 2m_magn	15	5.54	1.27	3.9	7.7	51.3	3.3	188.7	22.5	3.1	2.58		2.11	2.64

Crystal radiator adjacent to the amorphous converter.

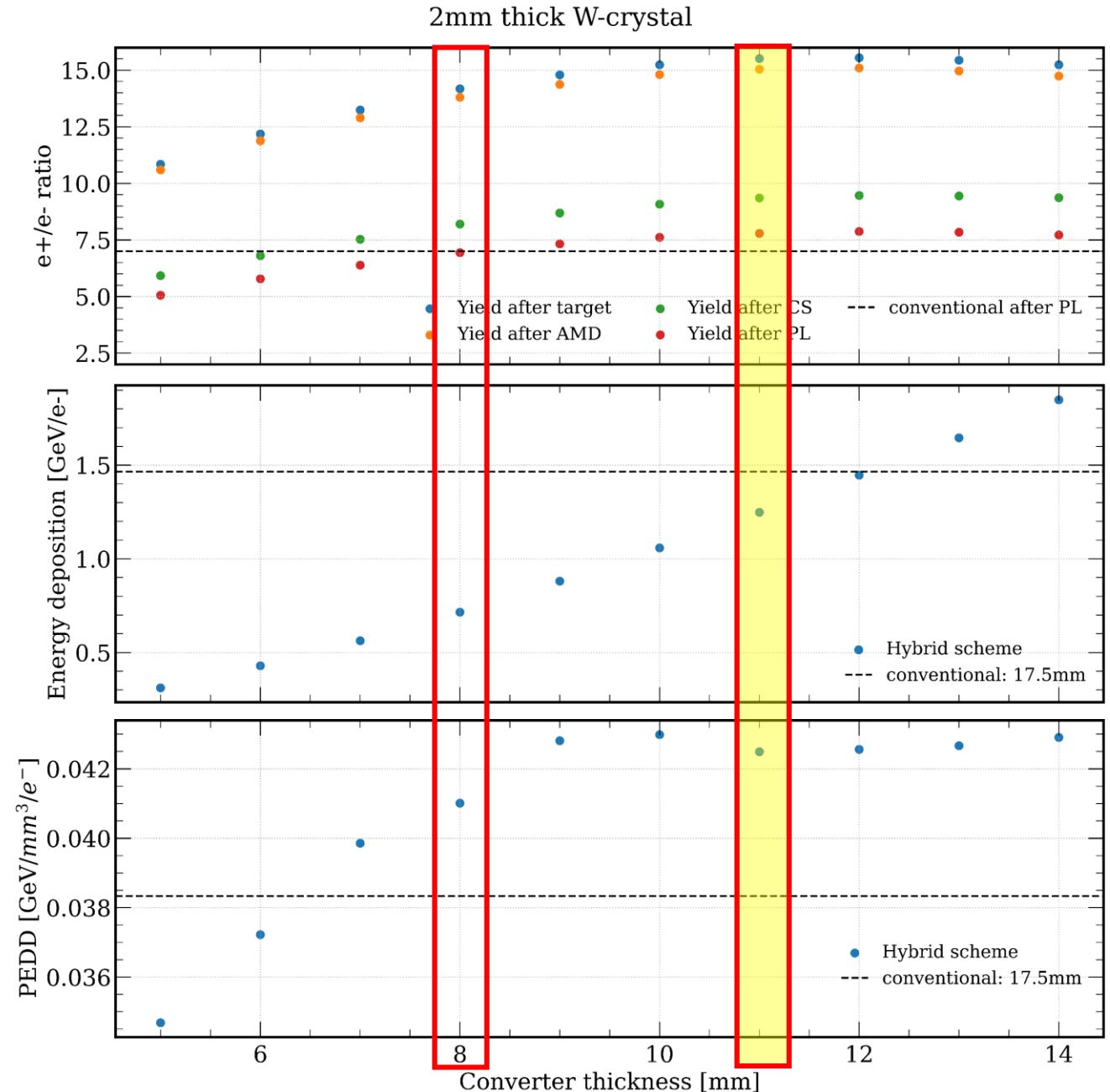
- In order to keep the beam size after the crystal as small as possible : crystal is placed adjacent to the converter (1mm gap).
- W-crystal $\langle 111 \rangle$ thickness: 1mm, 2mm, 3mm.
- For each crystal thickness a scan is performed to optimize the converter thickness [5:1:14] mm



Converter thickness optimization:

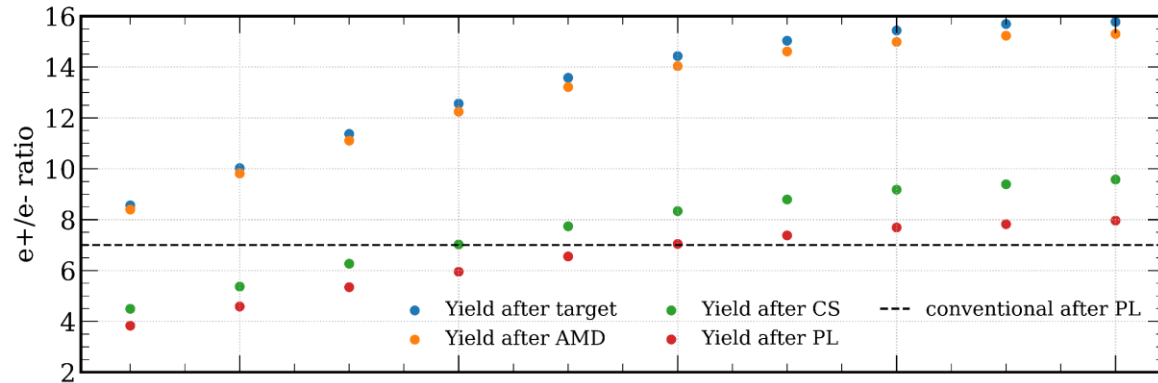
- An example of the optimization study with 2mm thick W-crystal in comparison with the conventional scheme.
- **Accepted yield: is comparable to the conventional for a shorter overall thickness (2mm + 8mm)**
- **Energy deposition: significantly lower than the conventional (~50%).**
- **PEDD: slightly higher than conventional (~7%)**

It is necessary to optimize the accepted yield not only the production rate after the target.

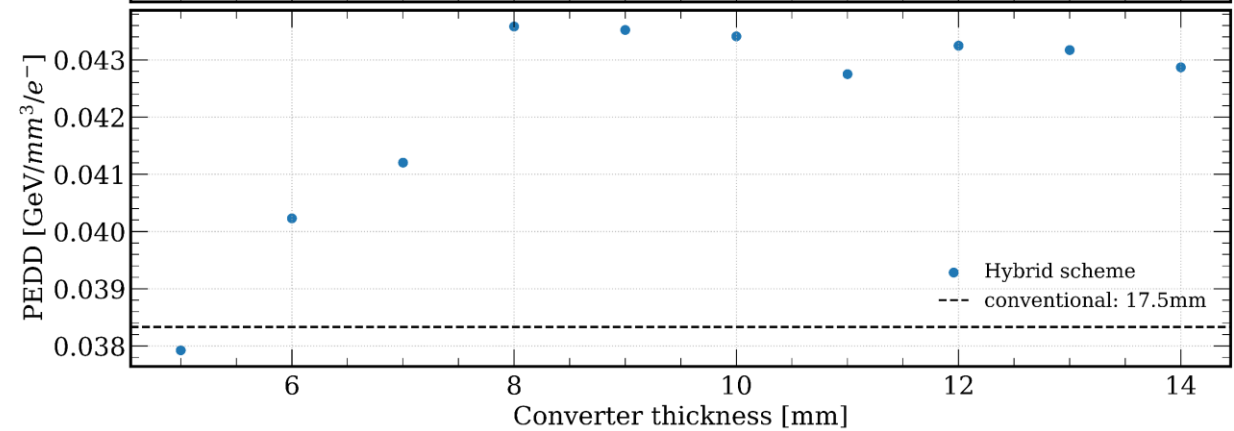
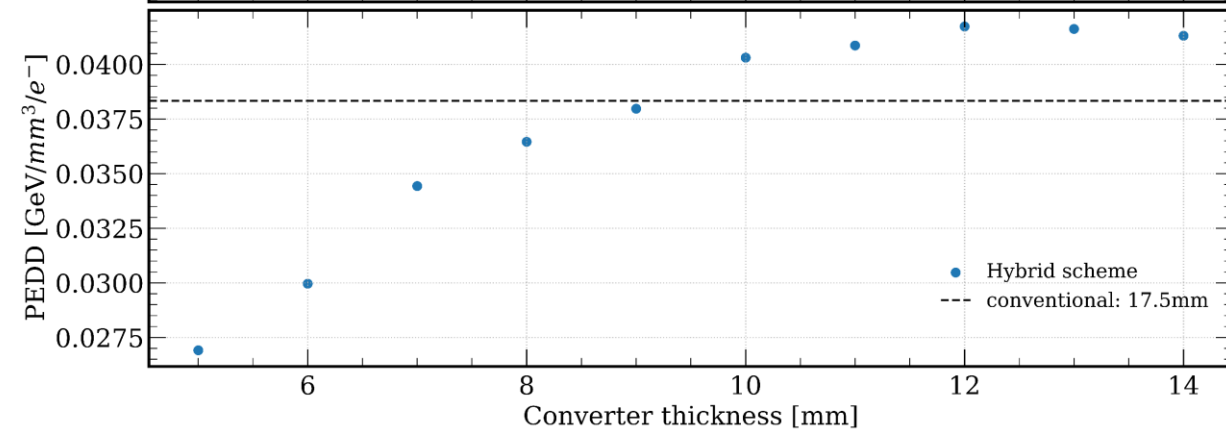
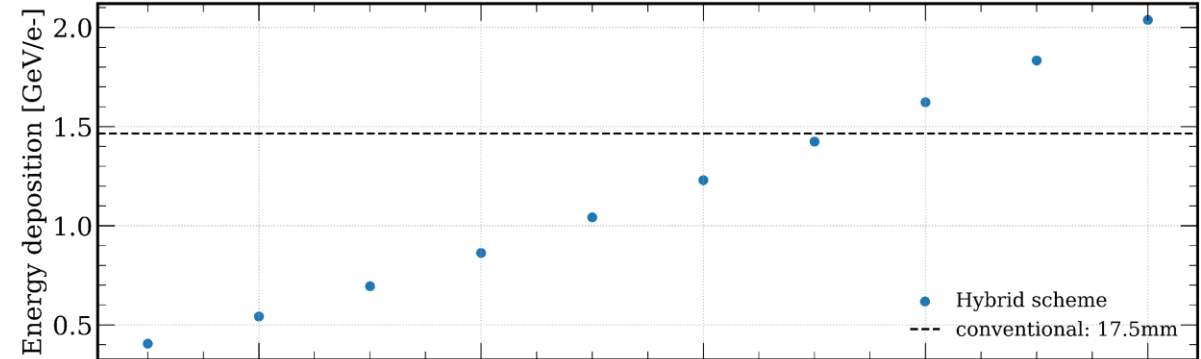
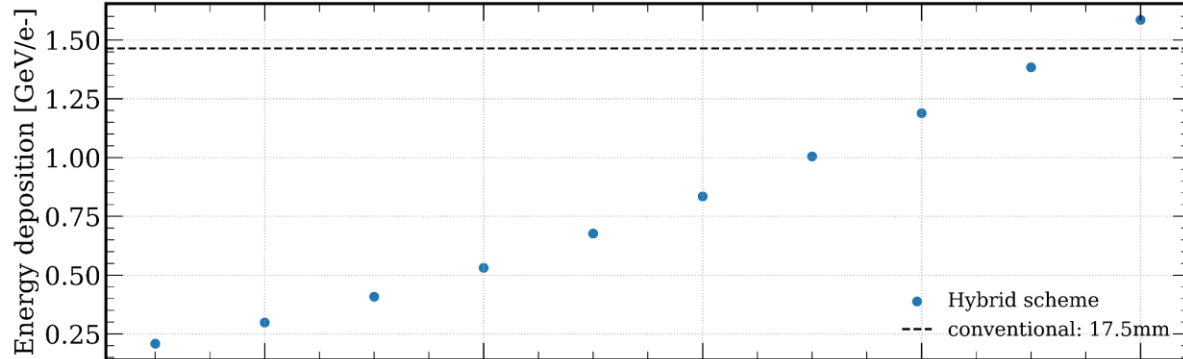
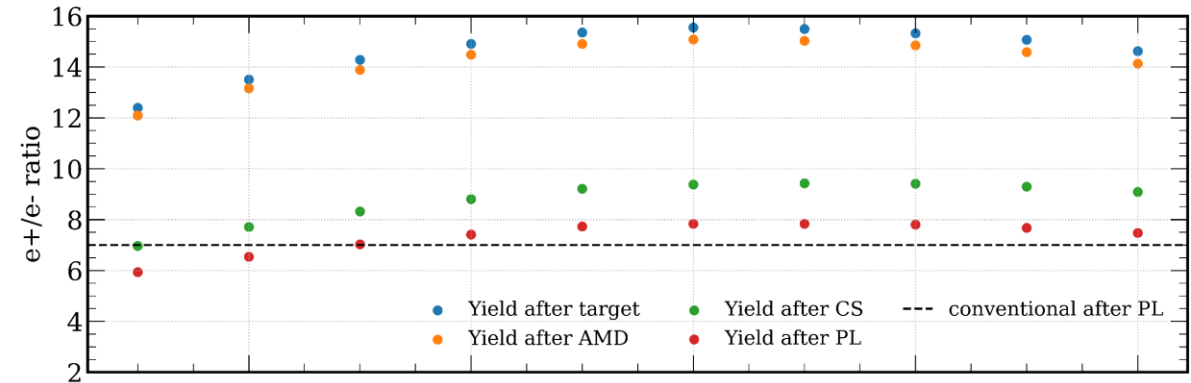


Hybrid scheme converter thickness optimization

1mm thick W-crystal



3mm thick W-crystal



Cases with final accepted yield is comparable with the conventional scheme

13.5nC at DR

Case	Thickness [mm]	Target				AMD	Capture Linac	Positron Linac	e- beam	Target	
		Rate	σx [mm]	Edep [GeV/e-]	PEDD [$\frac{MeV}{mm^3}/e^-$]	Yield (AMD) R = 30mm	Yield	Accept Yield	Drive beam charge [nC]	PEDD [J/g]	Power Deposited [kWs]
Conventional	17.5	14.4	0.85	1.46	38.3	13.1	8.6	7.0	1.93	7.67	1.12
1mm – 10mm	11	14.4	0.64	0.81	40.1	14	8.3	7.04	1.91	8	0.62
2mm – 8mm	10	14.2	0.64	0.73	41	13.8	8.2	6.9	1.96	8.33	0.57
3mm – 7mm	10	14.3	0.63	0.7	41.2	13.9	8.3	7.03	1.92	8.22	0.54

Hybrid scheme advantages in comparison with Conventional scheme :

- Shorter overall thickness (lower radioactive environment around the target) ?
- Comparable yield and PEDD with significantly lower power deposited in the target

Summary

- First check with Alexei previous output is done. (Positron capture simulation)
- Next steps: validation of the G4 simulation with previous results, then proceed with our plan: Timeline is extremely important.
- Hybrid scheme for positron production shows good advantages in comparison with the conventional scheme :
(lower power deposited => lower cooling requirements)

Further studies:

- Smaller primary beam size , thinner crystal.
- Applying one thick crystal instead of two targets (define a reasonable thickness and do simulation).

Thank you